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**FACSIMILE COVER SHEET**

To Examiner: Ha T. Nguyen	Total Pages Sent: 6
Technology Center 2800	(including cover sheet)
Facsimile Number: (703) 872-9306	Transmission Date: April 19, 2005

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

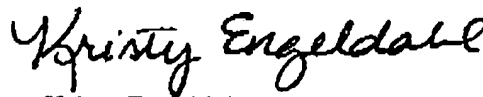
Applicant: Cheng, *et al.* Docket No.: TSM02-0971  
Serial No.: 10/635,621 Art Unit: 2812  
Date Filed: August 6, 2003  
TITLE: Method For Reducing Defects In Post Passivation Interconnect Process

**CERTIFICATION OF FACSIMILE TRANSMISSION**

I hereby certify that the following papers are being transmitted by facsimile to Mail Stop Amendment at the U.S. Patent and Trademark Office at (703) 872-9306 on April 19, 2005:

- Certification of Facsimile Transmission (1 page)
- Response to Office Action (5 pages)

Respectfully submitted,



Kristy Engeldahl  
Legal Assistant

Confirmation Respectfully Requested

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For: Method For Reducing Defects In Post Passivation Interconnect Process

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE TO OFFICE ACTION**

Applicant offers the following remarks as a full and complete response to the Office

Action dated February 24, 2005.